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3M-NANO is the annual International Conference on Manipulation, Manufacturing and Measurement on the Nanoscale; it will be held in 2015 in Changchun, China. The ultimate ambition of this conference series is to bridge the gap between nanosciences and engineering sciences, aiming at technology opportunities and new markets. The advanced technologies for manipulation, manufacturing and measurement at nanoscale promise novel revolutionary products and methods in numerous areas of application. Scientists working in research fields related to 3M-NANO topics are invited to submit papers. All accepted full papers (presented at the conference and following IEEE format) will be included in IEEE Xplore database and indexed by Ei Compendex. Selected papers will be recommended for publication in the IEEE Trans. on Automation Science & Engineering, Int. J of Nanomanufacturing, IFAC Mechatronics, Int. J of Optomechatronics, J of Micro-Bio Robotics, and other SCI/Ei journals.

**Organizers:** Jilin University, China

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**Changchun Association for Science and Technology** 

**Topics:** Specific topics include, but are not limited to

Nanohandling robots and systems Nanofabrication and nanoassembly Nanometrology and nanocharacterization Nanopositioning and nanomanipulation Nanosensing and microscopy AFM and SEM for nanohandling Process automation at nanoscale Self-assembly at nanoscale Nanoscale robotics Nanolithography Nanoenergy

Nanomaterials and applications Graphene and applications Nanoparticles, nanowires and nanotubes Nanoelectronics and nanomagnetics Nanophotonics and photonic crystals Nanomechanics and nanomechatronics NEMS and their applications **Nanofluidics** DNA detection and sequencing Bio-Nano devices and applications Bio-nanoimaging and nanomeasurement

High-profile keynote talks (20-25) on selected topics in manipulation, manufacturing and measurement on the nanoscale will be offered by distinguished international experts.

Social events: 3M-NANO aims at encouraging long-term partnerships and collaborative activities between experts in nanosciences and in engineering sciences. Get-together events will be organized by 3M-NANO as part of this effort.

Venue: The capital city of Jilin Province, known as the forest city, automobile city and film city, is located in the central part of Songliao Plain in Northeast China. Being one of the four Chinese Garden cities and host of 2007 Asian Winter Games, Changchun plays a pivotal role in the development of northeast China and enjoys a modern transportation infrastructure. Visit and enjoy Changchun at 3M-NANO 2015!

## **Important Dates**

Full paper submission Proposals for special sessions (5-6 papers)



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